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#16 COA

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

Fabrice Geiger et al.

Application No.: 09/701,065

Filing Date: February 12, 2001

For: Methods For Forming Self-Planarized
Dielectric Layer For Shallow Trench Isolation

Assistant Commissioner
for Patents
Washington, D.C. 20231

Examiner: Duda, Kathleen

Art Unit: 1756

Confirmation No.: 7160

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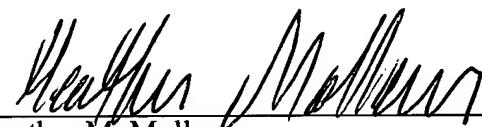
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Patent Counsel, MS/2061
Legal Affairs Dept.
Applied Materials, Inc.
P.O. Box 450A
Santa Clara, CA 95052

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Respectfully submitted,
BLAKELY, SOKOLOFF, TAYLOR & ZAFMAN LLP

Date: 03/26, 2003


Heather M. Molleur
Reg. No. 50,432

Patent Counsel
Legal Affairs Dept.
APPLIED MATERIALS, INC.
P.O. Box 450A
Santa Clara, CA 95052

Telephone inquiries to:
Heather M. Molleur
(408) 720-8300

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